

Notice of References Cited	Application/Control No. 10/721,164	Applicant(s)/Patent Under Reexamination NAKAMURA ET AL.	
	Examiner Amanda C. Walke	Art Unit 1752	Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	A	US-7,045,276	05-2006	Takahashi et al.	430/302
	B	US-			
	C	US-			
	D	US-			
	E	US-			
	F	US-			
	G	US-			
	H	US-			
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N	JP 10282672 A	10-1998	Japan	KAWAMURA et al.	
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	S					
	T					

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	English language abstract of JP 10-282672
	V	S.J.Whicher, J.L. Brash, J. of Polymer Science, Vol. 19, 1995-2006 (1981).
	W	S.J.Whicher, J.L. Brash, J. of Applied Polymer Science, Vol.30, 2297-2313 (1985).
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.